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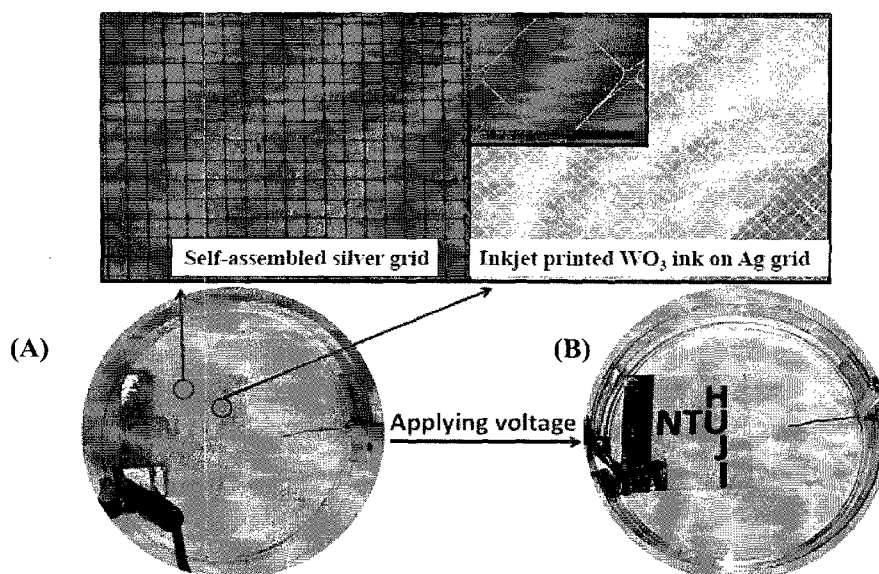
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[Continued on next page]

(54) Title: ELECTROCHROMIC DEVICE

FIG. 16



(57) Abstract: A method of manufacturing an electrochromic device is provided. The method includes providing a patterned arrangement of an electrically conductive material; and applying one or more layers of an electrochromic material to the patterned arrangement, wherein at least a portion of the electrochromic material is in electrical contact with the electrically conductive material. An electrochromic device and an electrochromic ink composition are also provided.



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